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An exceptionally facile method to produce layered double hydroxides on a conducting substrate and their application for solar water splitting without an external bias

Seungho Cho,[†] Ji-Wook Jang,[†] Yoon Bin Park, Jae Young Kim, Ganesan Magesh, Jin Hyun Kim, Minsu Seol, Kijung Yong, Kun-Hong Lee^{*} and Jae Sung Lee^{*}

Department of Chemistry, Department of Chemical Engineering and School of Environmental engineering science, Pohang University of Science and Technology (POSTECH), San 31, Hyoja-Dong, Pohang, South Korea, 790-784

School of Nano-Bio Science and Chemical Engineering, Ulsan National Institute of Science and Technology (UNIST), 50 UNIST-gil, Ulsan, South Korea 689-798

[†]These authors contributed equally to this work. ^{*}Corresponding authors: E-mail: ce20047@postech.ac.kr (K.-H.L.); jlee1234@unist.ac.kr (J.S.L.)



Figure S1. XRD pattern of Zn-deposited fluorine-doped tin oxide (FTO) glass.



Figure S2. XRD patterns of Zn-deposited FTO glass with different Cr nitrate solution-dipping times.



Figure S3. EDX pattern of particles detached from the substrate fabricated by the Cr nitrate solutiondipping process followed by calcination at 527°C in air for 2 h.



Figure S4. (A and B) XRD pattern and photograph of zinc chromium layered double hydroxide (ZnCr:LDH) powders synthesized by mixing of a 30 mL aqueous solution containing 1.4 M zinc nitrate hexahydrate and 0.6 M chromium nitrate nonahydrate and a 40 mL aqueous solution containing 3 M sodium hydroxide and 2.5 M sodium carbonate at 60°C for 24 h. (C and D) XRD pattern and photograph of zinc chromium mixed metal oxide (ZnCr:MMO) powders prepared by calcination of the ZnCr:LDH powders at 527°C in air for 2 h.



Figure S5. Photograph of the ZnCr:MMO/FTO glass fabricated by the Cr nitrate solution-dipping process followed by calcination at 527°C in air for 2 h.



Figure S6. Average photocurrent densities at 1.23 V (vs. RHE) normalized by that of the 1.5 μ m case as a function of Zn thicknesses. The photocurrent densities were measured in 0.2 M Na₂SO₄ solution (pH 6.5) under visible light irradiation (λ >420 nm) for the ZnCr:MMO/FTO glass fabricated by dipping of a Zn-deposited FTO glass in a Cr nitrate solution for 1 min, followed by calcination.



Figure S7. Average photocurrent densities at 1.23 V (vs. RHE) normalized by that of the 1 min dipping case as a function of dipping times. The photocurrent densities were measured in $0.2 \text{ M Na}_2\text{SO}_4$ solution (pH 6.5) under visible light irradiation.



Figure S8. Current–voltage curve in 0.2 M Na₂SO₄ solution (pH 6.5) under intermittent visible light irradiation (λ >420 nm) for the ZnCr:LDH/Zn/FTO glass fabricated by dipping of a Zn-deposited FTO glass in a Cr nitrate solution for 1 min.



Figure S9. Current–time curve of CoO_x -deposited ZnCr:MMO photoelectrode in a no-bias, twoelectrode configuration with a Pt wire cathode.



Figure S10. XRD pattern of a ZnCr:LDH/Zn substrate fabricated by immersing a Zn metal foil in Cr nitrate solution.